



Amendment in response to Office Action mailed 1/13/2003

2858/8
8/8
7/1/03
Roy

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re: US Patent Application 09/934,817
Filed August 21, 2001
Title Optical Arrangement and Projection Illumination Equipment for
Microlithography with Passive Thermal Compensation
Applicant Wagner
Art Unit 2858
Examiner Etienne (Steve) LaRoux
Telephone (703) 305-0620
Attorney Docket (Z) C98003 P US

Mail Stop Art Unit 2858 - Amendment with Extension Fees
Commissioner for Patents
PO Box 1450
Alexandria, Va. 22313-1450

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JUN 25 2003
TECHNOLOGY CENTER 2800

Amendment

Dear Examiner LaRoux:

This amendment responds to the Office Action mailed January 13, 2003.

In the Specification:

Please cancel paragraph [004] and replace it with the following replacement paragraph

[004] marked-up to show the changes made:

[0004] Active compensation of the imaging errors resulting from asymmetric thermal effects is

known from European Patent EP-A 0 678 768, and its corresponding application US Patent
5,803, 273 to Unno by regulated or controlled non-rotationally-symmetrical heating or cooling
and also, by way of a suggestion, by mechanical stressing.

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Wagner
(Z) 98003 P US
09/934,817